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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/955,600	09/19/2001	Nobuhiko Hayashi	990852A	1668	
38834	7590 03/05/2004		EXAMINER		
WESTERMAN, HATTORI, DANIELS & ADRIAN, LLP 1250 CONNECTICUT AVENUE, NW			NGUYEN,	NGUYEN, TUAN H	
SUITE 700		ART UNIT	PAPER NUMBER		
WASHINGT	ON, DC 20036	2813			

DATE MAILED: 03/05/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		A.S.			
	Application No.	Applicant(s)			
Office Action Commons	09/955,600	HAYASHI ET AL.			
Office Action Summary	Examiner	Art Unit			
	Tuan H. Nguyen	2813			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPL' THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.12 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period of the period for reply within the set or extended period for reply will, by statute any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be tin y within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from . cause the application to become ABANDONE	nety filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
Responsive to communication(s) filed on <u>30 December 2003</u> . This action is FINAL . 2b) This action is non-final. Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) ⊠ Claim(s) 1-3 and 12-17 is/are pending in the a 4a) Of the above claim(s) 1-3 and 14-17 is/are 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 12-13 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/or	withdrawn from consideration.	-			
Application Papers					
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Example 11.	epted or b) objected to by the drawing(s) be held in abeyance. Se tion is required if the drawing(s) is ob	e 37 CFR 1.85(a). sjected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
12) ☑ Acknowledgment is made of a claim for foreign a) ☑ All b) ☐ Some * c) ☐ None of: 1. ☐ Certified copies of the priority document 2. ☑ Certified copies of the priority document 3. ☐ Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	s have been received. s have been received in Applicat rity documents have been receive u (PCT Rule 17.2(a)).	ion No. <i>04/36/246 .</i> ed in this National Stage			
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:				

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DETAILED ACTION

Election/Restrictions

This application contains claims 1-3, 14-17 drawn to an invention nonelected with traverse in Paper No. dated 7/14/03. A complete reply to the final rejection must include cancellation of nonelected claims or other appropriate action (37 CFR 1.144) See MPEP § 821.01.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 12-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Wang et al..

Wang, figs. 3A-3F, 7 and text on col. 5-10 discloses the claimed semiconductor including a first nitride base semiconductor layer 70 formed on an insulating substrate 52 (fig. 3A, col. 5, lines 40-60); an irregular pattern including a plurality of recesses and projections being formed in the first nitride base layer 70 (figs. 3B, paragraph bridging col. 5-6, and fig. 7. col. 8, fourth paragraph); insulating film 56 is optionally formed on the bottom surface of a recess and the top surface of a projection of the irregular pattern of the semiconductor layer 70 (fig. 3C, col. 6, third paragraph); a second nitride base semiconductor layer 71 formed on the insulating films 56 containing at least one of 'ium, aluminum and indium; and third nitride based semiconductor layer 72, 73

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formed on the second nitride based semiconductor layer 71 (col. 4, first paragraph, figs. 3E, 3F, col. 6, fourth paragraph).

Wang does not particularly form an active region in the third nitride layer; however, on col. 10, lines 32-34, Wang suggests the step of forming active region in either second layer 71 of third layer 72,73.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have formed active region by introducing suitable dopants in any one of the epitaxial layer as suggested by Wang in order to obtain a desired device.

Response to Arguments

Applicant's arguments filed 12/30/03 have been fully considered but they are not persuasive. Since there is no distinction between the second and the third nitride base layers in the instant claim 12 therefore the top portion of the second layer could be considered as a third layer; secondly the instant claim 12 does not preclude the formation of active region in the second layer, and thirdly Wang clearly suggests to form active region in either second or third nitride base layers 71 or 72, 73 (col. 10, fifth paragraph).

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not

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mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 571-272-1694. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tuan H. Nguyen
Primary Examiner
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